

TEST REPORT (시 험 성 적 서)

신청기관 (인) : 씨앤씨테크㈜ APPLICANT : CNCTECH

시료 명세

주소 (한글) : 인천시 남동구 고잔로 41번길 23-1 (고잔동 390-1)

ADDRESS (ENGL.) : 23-1, Gojan-ro, 41beon-gil, Namdong-gu,

Incheon, Korea

발행면수 (PAGE):1 of 9

발행일자 (DATE): 2020. 01. 22.

시험성적서 번호 (REPORT NO.) :RT20R-S0259-K

:시료에 대한 상세한 정보는 아래와 같음

(SAMPLE DESCRIPTION) (The following submitted sample(s) said to be) 제품명/형식 : Cu Plating Solution (Additive M.F. Cu300)

(NAME/TYPE OF PRODUCT) (Cu Plating Solution (Additive M.F. Cu300))

재질 : Cu Plating Solution (VMS), Microfab Cu300 Starter, Microfab Cu300 SP, Microfab Cu300 LE,

(NAME OF MATERIAL) Microfab Cu300 BR, Cu Concentration)

(Cu Plating Solution (VMS), Microfab Cu300 Starter, Microfab Cu300 SP, Microfab Cu300 LE,

Microfab Cu300 BR, Cu Concentration))

시료고유번호 : RT20R-S0259 (SAMPLE ID NO.) (RT20R-S0259) 제품 생산자/공급자 : 씨앤씨테크㈜ (MANUFACTURER/VENDOR) (CNCTECH)

시료접수일자 : 2020. 01. 16. (SAMPLE RECEIVED) (Jan. 16, 2020)

시험일자 : 2020. 01. 16. ~ 2020. 01. 22. (TESTING DATE) : Jan. 16, 2020 ~ Jan. 22, 2020)

시험방법 : 이 시험성적서의 다음 페이지 첨부

(TEST METHOD) (Please see the following page)

시험결과 : 이 시험성적서의 다음 페이지 첨부

(TEST RESULT) (Please see the following page)

비고 (Notes): 1. 이 시험성적서는 제시된 시료 및 시료명으로 시험한 결과로서 유사 대상시료에 적용할 수 없음.

(The test results presented in this report refer only to the object tested.)

2. 이 시험성적서는 승인없이 복사 사용을 금함.

(This report shall not be reproduced except in full without the written approval of the testing laboratory.)

승인자 (Approved by)

장준용/기술책임자

권한자 (Authorized by)

박병옥/소장

(Bo Park / Lab. General Manager)

Authenticity check

Intertek Testing Services Korea Ltd.

(Jade Jang / Lab. Technical Manager)







(시 험 성 적 서)

발행면수 (PAGE): 2 of 9

시험성적서 번호 (REPORT NO.): RT20R-S0259-K 발행일자 (DATE): 2020. 01. 22.

시료고유번호 (SAMPLE ID NO.): RT20R-S0259

시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300) (Cu Plating Solution (Additive M.F. Cu300))

시험항목	단위	분석방법	검출한계	시험결과
(TEST ITEM)	(UNIT)	(TEST METHOD)	(MDL)	(RESULT)
카드뮴 (Cadmium, Cd)	mg/kg	With reference to IEC 62321-5 Edition 1.0 : 2013,	0.5	N.D.
납 (Lead, Pb)	mg/kg	by acid digestion and determined by ICP-OES	5	N.D.
수은 (Mercury, Hg)	mg/kg	With reference to IEC 62321-4 Edition 1.0 : 2013, by acid digestion and determined by ICP-OES	2	N.D.
6가 크롬 (Hexavalent Chromium, Cr ⁶⁺)	mg/kg	With reference to IEC 62321-7-2 Edition 1.0 : 2017, by alkaline/toluene digestion and determined by UV-VIS Spectrophotometer	8	N.D.
폴리브롬화비페닐 (Polybrominated Bipheny	/ls, PBBs)			T
모노브로모비페닐 (MonoBB)	mg/kg		5	N.D.
다이브로모비페닐 (DiBB)	mg/kg		5	N.D.
트라이브로모비페닐 (TriBB)	mg/kg		5	N.D.
테트라브로모비페닐 (TertaBB)	mg/kg	With reference to	5	N.D.
펜타브로모비페닐 (PentaBB)	mg/kg	IEC 62321-6 Edition 1.0 : 2015,	5	N.D.
헥사브로모비페닐 (HexaBB)	mg/kg	by solvent extraction and	5	N.D.
헵타브로모비페닐 (HeptaBB)	mg/kg	determined by GC/MS	5	N.D.
옥타브로모비페닐 (OctaBB)	mg/kg		5	N.D.
노나브로모비페닐 (NonaBB)	mg/kg		5	N.D.
데카브로모비페닐 (DecaBB)	mg/kg		5	N.D.
폴리브롬화디페닐에테르 (Polybrominated	Diphenyl Ether	rs, PBDEs)		
모노브로모디페닐에테르 (MonoBDE)	mg/kg		5	N.D.
다이브로모디페닐에테르 (DiBDE)	mg/kg		5	N.D.
트라이브로모디페닐에테르 (TriBDE)	mg/kg		5	N.D.
테트라브로모디페닐에테르 (TetraBDE)	mg/kg	With reference to	5	N.D.
펜타브로모디페닐에테르 (PentaBDE)	mg/kg	IEC 62321-6 Edition 1.0 : 2015,	5	N.D.
헥사브로모디페닐에테르 (HexaBDE)	mg/kg	by solvent extraction and	5	N.D.
헵타브로모디페닐에테르 (HeptaBDE)	mg/kg	determined by GC/MS	5	N.D.
옥타브로모디페닐에테르 (OctaBDE)	mg/kg		5	N.D.
노나브로모디페닐에테르 (NonaBDE)	mg/kg		5	N.D.
데카브로모디페닐에테르 (DecaBDE)	mg/kg		5	N.D.

Tested by: Jooyeon Lee, Seulgi Park, Miseon Lee

Notes: mg/kg = ppm = parts per million (함량 표시 : 백만분의 일)

< = Less than (결과 값 이하)

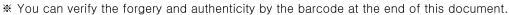
N.D. = Not detected (< MDL, 미검출 - 검출한계 이하)

MDL = Method detection limit (검출한계)

Intertek Testing Services Korea Ltd.









(시 험 성 적 서)

발행면수 (PAGE): 3 of 9

시험성적서 번호 (REPORT NO.): RT20R-S0259-K 발행일자 (DATE): 2020. 01. 22.

시료고유번호 (SAMPLE ID NO.): RT20R-S0259

시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300) (Cu Plating Solution (Additive M.F. Cu300))

,	(ear identify solution (reductive initial education))				
시험항목	단위	분석방법	검출한계	시험결과	
(TEST ITEM)	(UNIT)	(TEST METHOD)	(MDL)	(RESULT)	
브롬 (Bromine, Br)	mg/kg	With reference to EN 14582, by oxygen combustion with bomb and determined by IC	30	N.D.	
염소 (Chlorine, Cl)	mg/kg	With reference to EN 14582, by oxygen combustion with bomb and determined by IC	30	N.D.	
베릴륨 (Beryllium, Be)	mg/kg	With reference to US EPA 3052, by acid digestion and determined by ICP-OES	2	N.D.	
안티몬 (Antimony, Sb)	mg/kg	With reference to US EPA 3052, by acid digestion and determined by ICP-OES	2	N.D.	
퍼플루오로옥타노익에시드 (Perfluorooctanoic acid, PFOA)	mg/kg	With reference to US EPA 3550C/8321B, by ultrasonic extraction and determined by LC/MS or LC/MS/MS	0.1	N.D.	
퍼플루오로옥탄설포네이트 (Perfluorooctane sulfonate, PFOS)	mg/kg	With reference to US EPA 3550C/8321B, by ultrasonic extraction and determined by LC/MS or LC/MS/MS	0.1	N.D.	

Tested by: Hyojoo Kim, Miseon Lee, Jooyeon Lee

Notes: mg/kg = ppm = parts per million (함량 표시 : 백만분의 일)

< = Less than (결과 값 이하)

N.D. = Not detected (< MDL, 미검출 – 검출한계 이하)

MDL = Method detection limit (검출한계)

Intertek Testing Services Korea Ltd.







(시 험 성 적 서)

발행면수 (PAGE): 4 of 9

발행일자 (DATE): 2020.01.22. 시험성적서 번호 (REPORT NO.): RT20R-S0259-K

시료고유번호 (SAMPLE ID NO.): RT20R-S0259

시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300) (Cu Plating Solution (Additive M.F. Cu300))

시험항목	CAS번호	단위	분석방법	검출한계	시험결과
(TEST ITEM)	(CAS NO.)	(UNIT)	(TEST METHOD)	(MDL)	(RESULT)
디부틸프탈레이트 (Dibutyl phthalate, DBP)	84-74-2	mg/kg		50	N.D.
디에틸헥실프탈레이트 (Di-(2-ethylhexyl) phthalate, DEHP)	117-81-7	mg/kg	With reference to IEC 62321-8 Edition 1.0 : 2017,	50	N.D.
벤질부틸프탈레이트 (Benzyl butyl phthalate, BBP)	85-68-7	mg/kg	by solvent extraction and determined by GC/MS	50	N.D.
디이소부틸프탈레이트 (Diisobutyl phthalate, DIBP)	84-69-5	mg/kg	GC/IVI3	50	N.D.

Tested by: Miseon Lee

Notes: mg/kg = ppm = parts per million (함량 표시 : 백만분의 일)

< = Less than (결과 값 이하)

N.D. = Not detected (< MDL, 미검출 - 검출한계 이하)

MDL = Method detection limit (검출한계)

* 시료 접수 시 시료 상태 : (View of sample as received)



Intertek Testing Services Korea Ltd.







(시 험 성 적 서)

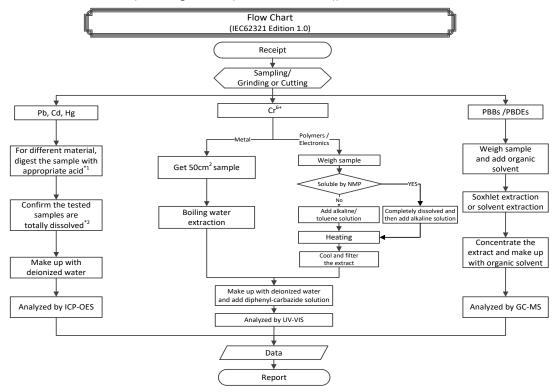
발행면수 (PAGE):5 of 9

발행일자 (DATE): 2020.01.22.

시험성적서 번호 (REPORT NO.): RT20R-S0259-K 시료고유번호 (SAMPLE ID NO.) : RT20R-S0259

시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300)

(Cu Plating Solution (Additive M.F. Cu300))



Remarks:
*1: List of appropriate acid:

٠,	ist of appropriate acid.	
	Material	Acid added for digestion
	Polymers	HNO ₃ , HCl, HF, H ₂ O ₂ , H3BO ₃
	Metals	HNO₃, HCl, HF
	Electronics	HNO ₃ , HCl, H ₂ O ₂ , HBF ₄

*2 : The samples were dissolved totally by pre-conditioning method according to above flow chart.

Intertek Testing Services Korea Ltd.







(시 험 성 적 서)

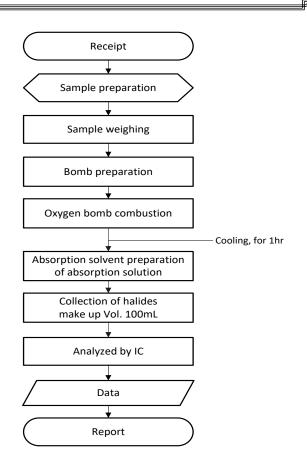
발행면수 (PAGE): 6 of 9 발행일자 (DATE): 2020.01.22.

시험성적서 번호 (REPORT NO.): RT20R-S0259-K

시료고유번호 (SAMPLE ID NO.): RT20R-S0259 시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300)

(Cu Plating Solution (Additive M.F. Cu300))

Flow Chart (EN14582)



Intertek Testing Services Korea Ltd.







(시 험 성 적 서)

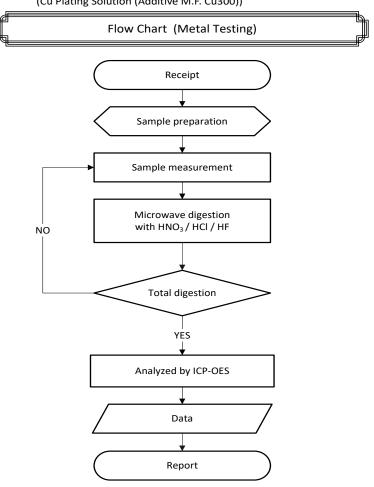
발행면수 (PAGE): 7 of 9 발행일자 (DATE): 2020. 01. 22.

시험성적서 번호 (REPORT NO.): RT20R-S0259-K

시료고유번호 (SAMPLE ID NO.): RT20R-S0259

시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300)

(Cu Plating Solution (Additive M.F. Cu300))



** 비고 : 이 샘플은 위의 흐름도에 따른 전처리 방법에 의해 완전용해 되었음. (The samples were dissolved totally by pre-conditioning method according to above flow chart.)

Intertek Testing Services Korea Ltd.







(시 험 성 적 서)

발행면수 (PAGE): 8 of 9 발행일자 (DATE): 2020. 01. 22.

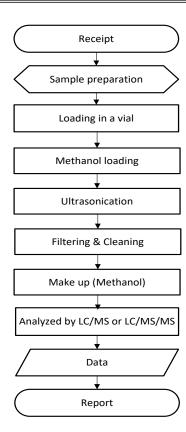
시험성적서 번호 (REPORT NO.) : RT20R-S0259-K

시료고유번호 (SAMPLE ID NO.) : RT20R-S0259

시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300)

(Cu Plating Solution (Additive M.F. Cu300))

Flow Chart (PFOS, PFOA)















(시 험 성 적 서)

발행면수 (PAGE):9 of 9

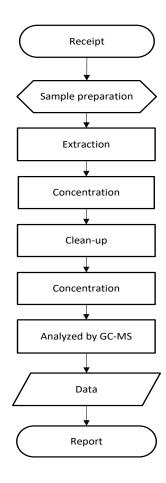
발행일자 (DATE) : 2020. 01. 22.

시험성적서 번호 (REPORT NO.) : RT20R-S0259-K

시료고유번호 (SAMPLE ID NO.) : RT20R-S0259

시료명 (SAMPLE DESCRIPTION) : Cu Plating Solution (Additive M.F. Cu300) (Cu Plating Solution (Additive M.F. Cu300))

Flow Chart (Phthalates)



***** End of Report *****

Except where explicitly agreed in writing, all work and services performed by Intertek is subject to our standard Terms and Conditions which can be obtained at our website: http://www.intertek.com/terms/. Intertek's responsibility and liability are limited to the terms and conditions of the agreement.

This report is made solely on the basis of your instructions and / or information and materials supplied by you and provide no warranty on the tested sample(s) be truly representative of the sample source. The report is not intended to be a recommendation for any particular course of action, you are responsible for acting as you see fit on the basis of the report results. Intertek is under no obligation to refer to or report upon any facts or circumstances which are outside the specific instructions received and accepts no responsibility to any parties whatsoever, following the issue of the report, for any matters arising outside the agreed scope of the works. This report does not discharge or release you from your legal obligations and duties to any other person. You are the only one authorized to permit copying or distribution of this report (and then only in its entirety). Any such third parties to whom this report may be circulated rely on the content of the report solely at their own risk.

This report shall not be reproduced, except in full.

This report is not related to the scope of Korea Laboratory Accreditation Scheme.

Intertek Testing Services Korea Ltd.







